

## Fabrication of L1<sub>0</sub>-FeNi by using Pulsed Laser Deposition (PLD) system

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Magnetic thin films with high magnetic anisotropy ( $K_u$ ) have been attracting huge attention for realization of next-generation spintronics devices. L1<sub>0</sub> type FeNi ordered alloy (L1<sub>0</sub>-FeNi) is a candidate for such applications because of large  $K_u$  and rare-metal free material [1]. For these industrial and environmental demands, the research of artificial fabrication is rapidly progressing in these days. Kojima *et al.* reported that  $K_u$  is proportional to chemical order parameter  $S$  [2]. Shen *et al.* also reported the comparison of surface morphology and perpendicular magnetization between molecular beam epitaxy (MBE) and pulsed laser deposition (PLD) mainly for iron thin films [3]. These reports point out that growth technique and interface roughness must be key issue to improve  $K_u$ . Here, we investigate how the magnetic anisotropy correlates with surface morphology, lattice structure and growth temperature of FeNi. We utilized PLD system, which can carry out almost ideal layer-by-layer epitaxial growth, to fabricate L1<sub>0</sub>-FeNi films.

Samples were prepared by PLD with Nd: YAG laser (wave length: 266 nm). Iron seed layer (1nm) and Au, Cu layer were deposited on the MgO(100) substrate. Substrate temperature during Cu deposition was 300 °C, which is optimized in the previous study by surface observation using atomic force microscope (AFM). Fe/Ni (50ML) multilayer was deposited by alternate monoatomic deposition. We varied substrate temperature ( $T_s$ ) during FeNi deposition from RT to 400 °C. Surface morphology of sample was observed by AFM. Synchrotron radiation XRD(SR-XRD) measurement was conducted to reveal structural properties and estimate  $S$ . Magnetic properties were estimated by a superconducting quantum interference device (SQUID) magnetometer.

Figure 1(a) and 1(b) show the diffraction pattern of SR-XRD around FeNi(110) superlattice peak and FeNi(220) fundamental peak, respectively. FeNi(110) superlattice peak was clearly observed for all samples. This indicates L1<sub>0</sub> structure was formed for all samples. Superlattice peak shows maximum intensity at 300 °C of  $T_s$ , suggesting that L1<sub>0</sub>-ordering was promoted by annealing. This temperature almost corresponds to order-disorder transition temperature (320 °C) of L1<sub>0</sub>-FeNi phase. Surface roughness is also investigated by AFM, and atomically flat surface was observed for around 90 % of observed area.

Figure 2 shows magnetization curves for the sample of  $T_s = 300$  °C. Saturation magnetization ( $M_s$ ) was 800 emu/cc and its easy axis was in-plane.  $K_u$  was estimated to  $1.60 \times 10^6$  erg/cc, and it was the largest value among various deposition temperature.

It is concluded that magnetic anisotropy was improved by structural ordering through annealing, and optimum annealing temperature (300°C) almost corresponds to order-disorder transition temperature (320 °C) of FeNi phase. It suggests that improvement of magnetic anisotropy is promoted by atomic flatness in terms of crystallographic structure and morphology.

[1] M. Kotsugi *et al.*, Appl. Phys. Express. **2**, 013001, (2010)

[2] T. Kojima *et al.*, Jpn. J. Appl. Phys. **51**, 010204, (2012)

[3] J. Shen *et al.*, Surf. Sci. Rep. **52**, 163-218, (2004)

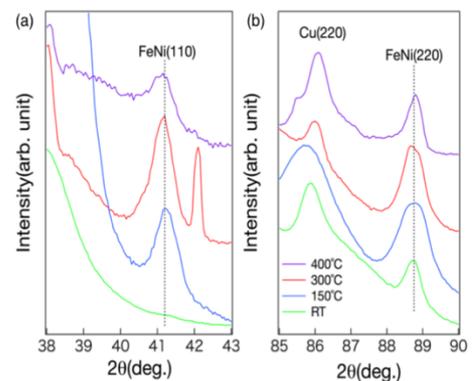


Fig. 1 Diffraction patterns of SR-XRD using X-ray with 7.11 keV.

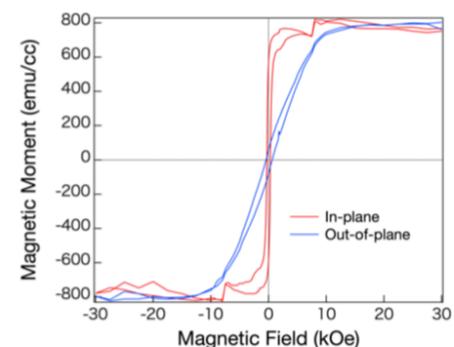


Fig. 2 Magnetization curve of FeNi for 300 °C of  $T_s$ .